

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	Method of Forming Silicon Dioxide Using Siloxane
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Application Number : 10/782094



Confirmation Number: 4756

First Named Applicant: Jae-Eun Park

Attorney Docket Number: SAM-0483

Art Unit:

Examiner:

Search string: (6664156 or 5037514 or 6534395 or 20020164890 or 20030015764 or 20020047151).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6664156	2003-12-16	Ang, et al.			
	2	5037514	1991-08-06	Yamazaki			
	3	6534395	2003-03-18	Werkhoven, et al.			

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
	1	20020164890	2002-11-17	Kwan, et al.			
	2	20030015764	2003-01-23	Raaijmakers, et al.			
	3	20020047151	2002-04-25	Kim, et al.			

Remarks

Note: Remarks are not for responding to an office action.

part 1 of 1

Signature

Examiner Name	Date